ROTATIONAL TRANSFER BENCH

For Etch, Develop or Cleaning: in 2-bath or 4-bath Rotational Process Configurations

- Adaptable for any bath configuration, from temperature controlled etch to megasonic cleaning
- Can be programmed for critical timed transfer and process agitation
- Standard tool designs include Allen Bradley SLC500 Series PLC
- Stepper motor control provides smooth, quiet service, with reduced process down-time
- Graphic Operator Interface for trending, alarm log and data collection
- Capacity of model at right is 2-boat 150mm wafer carriers







- Rotational front to rear, or side to side, with vertical axis
- Tank perimeter and rear deck exhaust, with rear, top or bottom connection
- Optional light curtain for operator safety
- Clean, reliable operation
- Materials of construction include polypropylene, fireretardant polypropylene, or FM 4910 approved materials
- Many other bath and control component configurations are available



The bench at left features an interchangeable boat rack design, which allows processing of either 2-boat 150mm or 1-boat 300mm wafers.

SEMI S2 Product Testing and Certification Available

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All specifications are subject to change without notice.



DESIGN, PLASTIC FABRICATION AND PROCESS EQUIPMENT FOR THE SEMICONDUCTOR, PRINTED CIRCUIT BOARD AND PLATING INDUSTRIES

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